

In the claims:

1. (CURRENTLY AMENDED) A silver alloy for use in a reflection film, ~~comprising~~ consisting of silver, gallium as a main component, and at least one metal element as a first additive element, having lower melting point than that of silver and at least either dysprosium or thulium as a second additive element.

2. (CANCELED)

3. (CANCELED)

4. (CANCELED)

5. (CANCELED)

6. (CURRENTLY AMENDED) A silver alloy for use in a reflection film according to ~~claim 5~~ claim 1, wherein said second additive element is ~~at least any of platinum, palladium, thulium, or dysprosium.~~

7. (CURRENTLY AMENDED) A silver alloy for use in a reflection film according to claim 1, wherein the total concentration of the additive elements is 0.01-5.0 atomic %.

8. (CURRENTLY AMENDED) A silver alloy for use in a reflection film according to claim 7, wherein the total concentration of the additive elements is 0.01-1.5 atomic %.

9. (CURRENTLY AMENDED) A sputtering target ~~comprising~~ consisting of the silver alloy, which silver alloy being defined in claim 1.

10. (CANCELED)

11. (CANCELED)

12. (CANCELED)

13. (NEW) A silver alloy for use in a reflection film according to claim 1, wherein said second additive element is thulium.

14. (NEW) A sputtering target consisting of the silver alloy, which silver alloy being defined in claim 7.

15. (NEW) A sputtering target consisting of the silver alloy, which silver alloy being defined in claim 8.